

<p align="center"><b>NATIONAL PHASE UTILITY APPLICATION</b></p> <p align="center"><b>Transmittal to the (DO/EO/US) Under 35 USC 371</b></p>	<p>Attorney Docket No.: SHIGA7.035APC  First Named Inventor: Yasushi Washio  Int'l Application No.: PCT/JP2004/009077  Int'l Filing Date: June 22, 2004  Priority Date Claimed: June 27, 2003  Title: DEVELOPER COMPOSITION FOR RESISTS AND  METHOD FOR FORMATION OF RESIST PATTERN  Express Mail Label No.: EV718232928US</p>
<p><b>Direct all correspondence to Customer No.: 20995</b> <span style="float: right;">Date: December 22, 2005 Page 1 of 3</span></p>	

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The following enclosures are transmitted herewith to be filed in the patent application of:

Inventors:

1. Yasushi Washio
2. Koji Saito

**APPLICATION ELEMENTS:**

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as filed (35 U.S.C. § 371(c)(2)) has been communicated by the International Bureau.
  - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is attached hereto.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

**OTHER APPLICATION PARTS:**

- (X) Preliminary Amendment in 5 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
  - (X) Listing 5 references.
  - (X) Enclosing 3 references.
- (X) International Search Report and Written Opinion.
- (X) Cover page of PCT publication WO 2005/001578 A2.
- (X) Return prepaid postcard.

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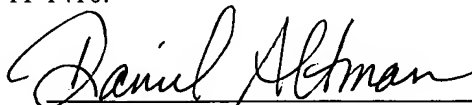
<b>NATIONAL PHASE UTILITY APPLICATION</b>  <b>Transmittal to the (DO/EO/US)</b> <b>Under 35 USC 371</b>	Attorney Docket No.: SHIGA7.035APC First Named Inventor: Masashi Washio Int'l Application No.: PCT/JP2004/009077 Int'l Filing Date: June 22, 2004 Priority Date Claimed: June 27, 2003 Title: DEVELOPER COMPOSITION FOR RESISTS AND METHOD FOR FORMATION OF RESIST PATTERN Express Mail Label No.: EV718232928US
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 Date: December 22, 2005  
 Page 2 of 3
**FILING FEES:**

FEE CALCULATION				
FEE TYPE & DETERMINATION		LARGE FEE	CALCULATION	TOTAL
Basic Filing Fee under 1.492(a)		1631 (\$300)		\$300
Search Fee under 1.492(b) (enter one in TOTAL column)				
(1)	USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)	1640 (\$0)		\$400
(2)	USPTO was the ISA (noncompliant claims)	1641 (\$100)		
(3)	Foreign Search Report Enclosed	1642 (\$400)		
(4)	No Search Report Enclosed	1632 (\$500)		
Examination Fee under 1.492(c) (enter one in TOTAL column)				
(1)	USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)	1643 (\$0)		\$200
(2)	Non US IPEA or Noncompliant Claims	1633 (\$200)		
Excess Claims	4 - 20 = 0	1615 (\$50)	0 x 50 =	\$0
Excess Ind. Claims	1 - 3 = 0	1614 (\$200)	0 x 200 =	\$0
Multiple Dep. Claim		1616 (\$360)		\$0
Application Size Fee	0 - 100 = 0	1681 (\$250)	0 x 250 =	\$0
Late English Translation		1618 (\$130)		
Assignment		8021 (\$40)	1 x 40 =	\$40
			<b>TOTAL FEE DUE</b>	<b>\$940</b>
<b>TOTAL FEE PAID (If Different Than Fee Due)</b>				<b>\$</b>

(X) A check in the amount of \$940 to cover the Total Fee Due is enclosed.

The Commissioner is hereby authorized to charge any additional fees which may be required, now or in the future, or credit any overpayment to Account No. 11-1410.



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<p><b>NATIONAL PHASE UTILITY APPLICATION</b></p> <p><b>Transmittal to the (DO/EO/US) Under 35 USC 371</b></p>	<p>Attorney Docket No.: 100247035-APC First Named Inventor: Yasushi Washio Int'l Application No.: PCT/JP2004/009077 Int'l Filing Date: June 22, 2004 Priority Date Claimed: June 27, 2003 Title: DEVELOPER COMPOSITION FOR RESISTS AND METHOD FOR FORMATION OF RESIST PATTERN Express Mail Label No.: EV718232928US</p>
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Daniel E. Altman

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Alexandria, VA 22313-1450**CERTIFICATE OF MAILING BY "EXPRESS MAIL"**

**Attorney Docket No.** : SHIGA7.035APC

**Applicant(s)** : Washio et al.

**For** : DEVELOPER COMPOSITION FOR RESISTS  
AND METHOD FOR FORMATION OF  
RESIST PATTERN

**Attorney** : Daniel E. Altman

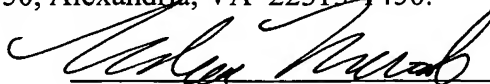
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**Date of Deposit** : December 22, 2005

I hereby certify that the accompanying

Transmittal letter; English translation of specification in 19 pages; Preliminary Amendment in 5 pages; signed Declaration and Power of Attorney in 2 pages; Recordation Form Cover Sheet and Assignment in 3 pages; cover page of PCT publication; International Search Report and Written Opinion; PCT/IB/308; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 3 references; Check for Filing Fee; Return Prepaid Postcard

are being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated above and are addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.



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